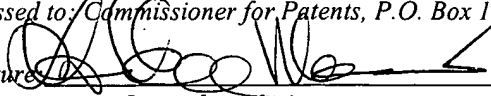


CERTIFICATE OF MAILING (37 CFR 1.8(a))

I hereby certify that this correspondence (along with any referred to as being attached or enclosed) is being deposited with the United States Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on February 25, 2004.

Signature: 

Laura Lee Mosier

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:
Yoshihide SENZAKI

Serial No. 10/766,618

Filed: January 27, 2004

For: Multilayer High K Dielectric Films
And Method of Making Same

Art Unit: To be assigned

Examiner: To be assigned

Date: February 25, 2004

INFORMATION DISCLOSURE STATEMENT SUBMITTED
PRIOR TO THE FIRST OFFICIAL ACTION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Applicant submits herewith patents and publications which may be material to the examination of this application and in respect of which there may be a duty to disclose in accordance with 37 C.F.R. § 1.56. While this Statement may be "material" pursuant to 37 C.F.R. § 1.56, it is not intended to constitute an admission that any patent, publication, or other information referred to therein is "prior art" for this invention unless specifically designated as such.

Enclosed herewith are PTO/SB/8A and PTO/SB/8B forms listing art potentially relevant or of interest to the referenced patent application. This application relies on the earlier filing date of prior Application No. 10/056,625, filed January 25, 2002, under 35 U.S.C. § 120. It is understood that the Examiner will consider information that was submitted to or cited by the Office in such prior applications. Copies of documents previously submitted to or cited by the Office in the prior application are not required to be provided in this application and thus are not attached. 37 C.F.R. § 1.98(d).

To satisfy the duty of disclosure under 37 CFR § 1.56 and MPEP § 2001.06(b), Applicant notes that the present application is related to pending U.S. Application Serial No. 10/056,625, filed January 25, 2002 and U.S. Application No. 10/766,148 filed January 27, 2004.

This information disclosure statement is being filed in compliance with 37 CFR § 1.97(b)(3) as being filed before the mailing date of the first office action on the merits.

Should any questions or comments arise regarding the listing of the submitted publications and patents in which the Examiner feels a telephone conversation would be appropriate, he or she is respectfully requested to contact the undersigned attorney at the listed telephone number.

Respectfully submitted,

DORSEY & WHITNEY LLP



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(use as many sheets as necessary)

Application Number	10/766,618
Filing Date	January 27, 2004
First Named Inventor	Yoshihide SENZAKI
Group Art Unit	Not yet assigned
Examiner Name	Not yet assigned
Attorney Docket Number	A-70028-1/MSS/TJH

Sheet	1	of	2
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[illegible]

Examiner Initials*	Cite No. ¹	Foreign Patent Document			Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ⁶
		Office ³	Number ⁴	Kind Code ² <i>(if known)</i>				

Examiner Signature		Date Considered	
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¹ Unique citation designation number. ² See attached Kinds of U.S. Patent Documents. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to place a check mark here if English Language Translation is attached.

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PTO/SB/8B (08-00)

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(use as many sheets as necessary)</i>				Complete if Known	
				Application Number	10/766,618
				Filing Date	January 27, 2004
				First Named Inventor	Yoshihide SENZAKI
				Group Art Unit	Not yet assigned
				Examiner Name	Not yet assigned
Sheet	2	of	2	Attorney Docket Number	A-70028-1/MSS/TJH
OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS					
Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.			T ²
	C1	MANCHANDA et al., "Si-Doped Aluminates for High Temperature Metal-Gate CMOS: Zr-Al-Si-O, A Novel Gate Dielectric for Low Power Applications, 2000 <i>IEEE</i> , pp. 15-18.			
	C2	WILK et al., "Electrical Properties of Hafnium Silicate Gate Dielectrics Deposited Directly on Silicon", <i>Applied Physics Letter</i> , vol. 74, 1999, pp. 2854-2856.			
	C3	WILK et al., "Stable Zirconium Silicate Gate Dielectrics Deposited Directly on Silicon", <i>Applied Physics Letters</i> , vol. 76, no. 1, January 3, 2000, pp. 112-114.			
	C4	WOLFE, D., et al., "Remote Plasma Enhanced-Metal Organic Chemical Vapor Deposition of Zirconium Oxide/ Silicon Oxide Alloy, (ZrO ₂) _x -(SiO ₂) _{1-x} (x ≤ 0.5), Thin Films for Advanced High-K Gate Dielectrics", <i>Materials Research Society Symposium</i> , vol. 567, 1999, pp. 343-348.			
Examiner Signature				Date Considered	

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. ¹ Unique citation designation number. ² See attached Kinds of U.S. Patent Documents. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to place a check mark here if English Language Translation is attached. Burden Hour Statement: This form is estimated to take 2.0 hours to complete. Time will vary depending upon the needs of the individual case. Any comments on the amount of time you are required to complete this form should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, Washington, DC 20231.